



RenoNix Recommend Equipment NIKON NSR-2005i10C System

2019.02.20



NIKON NSR-2005i10C

Configuration

Equipment Maker	NIKON	RN NO.	RNX20190219-02
Equipment model	NSR-2005i10C	Wafer Size	6inch
Vintage	1995	Chamber Size Chamber EPROM Ver.	Body : 1950mm S04-00 Ver 1.3
Electric Source	NEMA BOX For (CVCF)	Chamber Type	SENDAI
HP LASER	5517B	Computer Type	NEST3
Set Temperature	Chamber : 23°C, LLTC :23°C, IATC : 23°C	LAMP Power	1.75kW
Reticle Microscope	Fixed	LSA LASER	5mW
Wafer Condition	Silicon / Wafer Size (3")	Chuck Type	Ring
OF Detection Type	Keyence Type	Wafer Stage	Ball Screw
Wafer Loader Type	Type 1	Wafer Type	Flat
Wafer Carrier Table	Right / Extra	In-Line	No.
Reticle Size	6 inch	FIA	Yes
Reticle Library Type	Nikon	Slot	Main : (O) Slot/13 Ext. LIB : (O) Slot 13
Rack Type	Normal (Right)		
PPD / PD	PPD (no), PD (no)		
SHRINC Type	Type1	Illumination Setting	-
Note	Initailize Condition / No Missing Parts		

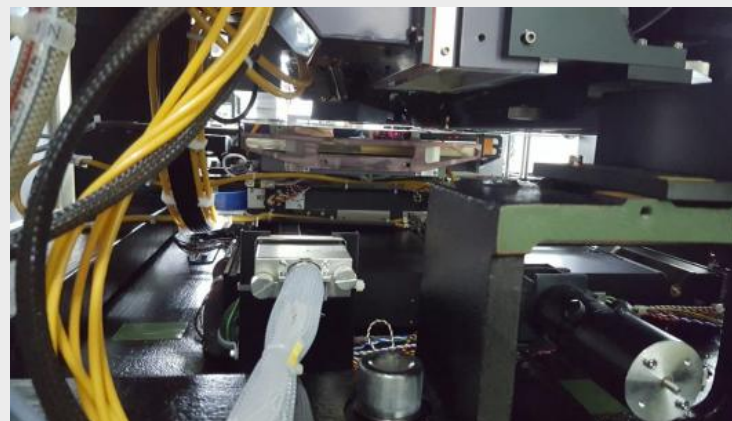
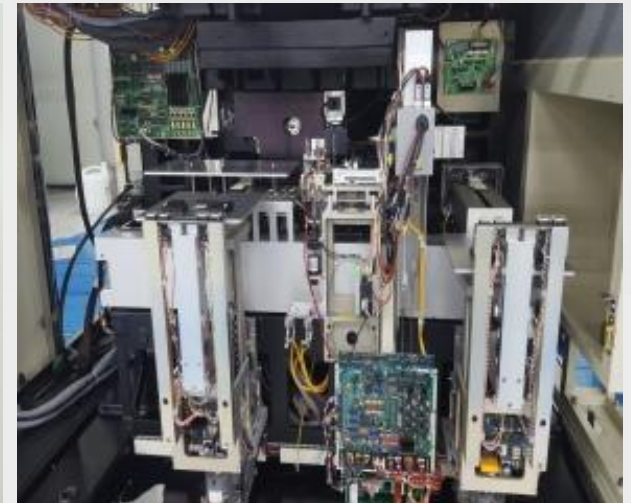
NIKON NSR-2005i10C

Main Body



NIKON NSR-2005i10C

Main Body



Nikon
NSR-2005i10C
NO. 1004178
NIKON CORPORATION
MADE IN JAPAN

NIKON NSR-2005i10C

Operation Rack



NIKON NSR-2005i10C

Operation Rack



NIKON NSR-2005i10C

Refrigerator



NIKON NSR-2005i10C

Lamp Power & Uniformity



Contact Point

We're Capable of Most of service for PVD,CVD, ETCH areas.
If you have any inquiry or interest , please feel free to contact us.



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